

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q80754

Kesahiro KOIKE

Appln. No.: 10/809,419

Group Art Unit: 1763

Confirmation No.: 6804

Examiner: George A. Goudreau

Filed: March 26, 2004

For: METHOD OF PRODUCING A GLASS SUBSTRATE FOR A MASK BLANK AND
METHOD OF PRODUCING A MASK BLANK

RESPONSE UNDER 37 C.F.R. § 1.111

MAIL STOP AMENDMENT

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Sir:

In response to the Office Action dated September 28, 2007, please amend the above-identified application as follows on the accompanying pages.

REMARKS

Claims 1-24 are all the claims pending in the application. Claims 1-5 and 7-24 are rejected. Claim 6 is objected to but would be allowable if placed in to independent form. No claims are amended.

Claim Rejections - 35 U.S.C. § 103

Claims 1-5, and 7-24 are rejected under 35 U.S.C. 103(a) as being unpatentable over Best et. al (2002/0043080) further in view of Hata et. al. (JP 63-114,866), and Takeuchi et. al. (2002/0179576). This rejection is traversed for at least the following reasons.

Claim 1

The Examiner now combines Best with the previously cited references to Hata et al and Takeuchi et al in order to remedy the deficiencies identified by the Applicant in the previous